



Fulflo® Slurry-Mate™ Filter Cartridges

■ Polypropylene

Pleated Series

Maximize Planarization Yield with Slurry-Mate Filter Cartridges

Parker's Fulflo CMP Slurry-Mate Filter Cartridges provide uniform slurry delivery while optimizing the chemical mechanical planarization of wafer interlayer dielectric (ILD) and tungsten and copper metal layers. A unique proprietary melt blown media provides a particle classification effect, which improves service life while maintaining optimum polishing characteristics of alumina and silica based slurries.

Several particle classification matrices are available to match the wide range of CMP oxide and metal polishing slurries in recirculation and distribution loops as well as point-of-use CMP tools.

Applications

Oxide Polishing Slurries:	Metal Polishing Slurries:
Point of Use	Point of Use
Distribution	Distribution
Recirculation Loop	Recirculation Loop



Features and Benefits

- Classification matrix extends slurry life and maintains consistent slurry delivery.
- All polypropylene construction provides excellent compatibility for both acidic and basic slurries.
- Sieve-like filtration matrix provides sharp particle size cutoff to remove only agglomerated particles causing wafer surface damage.
- Heavy duty construction handles rigors of CMP process fluid conditions.
- Increase wafer yield by removing oversized, agglomerated or foreign particulate matter.
- Large Surface area provides high flux rate.
- All polymeric construction is totally incinerable.
- Thermal bonding eliminates particle bypass.
- Parker's TQM system assures consistent performance.
- Several classification matrices are available to accommodate wide range of polishing slurry formulations.
- Fits standard Fulflo and similar competitive filter vessels.

Process Filtration Division



Pleated Series

Specifications

Particle Classification Codes:

- 02, 04, 06, 08, 10, 12, 14, 16

Materials of Construction:

- Filter Medium: Melt Blown Polypropylene
- Filter Medium Support: Polypropylene
- Structural Components: Natural polypropylene
- O-Ring Material: EPDM, Viton, PFA/Viton
- Gasket Material: Polyethylene Foam
- Sealing Method: Thermal bonding

Flow Factors (psid/gpm @ 1 cks per 10-inch cartridge)

Code	Flow Factors
02	1.00
04	0.75
06	0.50
08	0.13
10	0.03
12	0.02
14	0.01
16	0.01

$\Delta P = \text{Flow Rate} \times \text{Viscosity} \times \text{Flow Factor}$

Dimensions:

- Diameter: 2.5 in (64 mm)
- Lengths: 4-30 in (102-764 mm)

Maximum Recommended Operating Conditions:

- Temperature: 200°F (93°C) @ 10 ΔP (0.7 bar)
- Differential Pressure: 70 psi (4.8 bar) @ 77°F (25°C)
10 psi (0.7 bar) @ 200°F (93°C)
- Flow Rate: 10 gpm (38 lpm) per 10 in cartridge
- Changeout Net ΔP : 10 psi (0.7 bar)

Cartridge Selection Guide

Slurry Particle Size Range (micrometers)	Recommended Cartridge Code	Typical Application
0.05 - 0.1	02	Point of Use
0.10 - 0.2	04	
0.20 - 0.4	06	
0.50 - 1.0	08	Distribution
1.00 - 2.0	10	
2.00 - 4.0	12	Recirculation Loop
4.00 - 8.0	14	
7.00 - 14.0	16	

Note: Cartridge selection based on removing particles larger than the slurry particle size range specified.

Ordering Information

SMC	12	10	N	V	TC
Cartridge Code	Particle Classification Code	Nominal Length	Support Construction	Seal Material	End Cap Configuration
SMC = Slurry-Mate Cartridge	02 04 06 08 10 12 14 16	Code (in) (mm) 04 4 102 10 9-13/16 249 20 19-15/16 506 30 30-1/16 764	N = Natural Polypropylene	A = Polyethylene Gasket (DO Only) E = EPDM O-ring T = PFA/Viton* O-ring V = Viton* O-ring	DO = Double Open End TC = 222 O-ring/Cap

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Parker Hannifin Corporation
Process Filtration Division
6640 Intech Boulevard
Indianapolis, Indiana 46278
Toll Free 1-800-C-FULFLOW (238-5356)
Telephone (317) 275-8300
Fax (317) 275-8410
<http://www.parker.com>



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